

## PATENT ASSIGNMENT COVER SHEET

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Invention Title: Projected Beam Pen Lithography for Benchtop High Resolution Maskless Photolithography of Large Areas

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Child Invention EIR 6144601-12-0045 Additional grant numbers: FA2386-10-1-4065; FA9550-12-1-0280; FA9550-12-1-0141; DBI1152139; CA151880

Foreign Applications filed/intended in (countries): China, Singapore, European Community

The invention identified above is a Subject Invention under 35 U.S.C. 200, et seq., and the Standard Patent Rights clause at 37 CFR 401.14, FAR 52.227-11 or FAR 52.227-12 (if applicable) which are included among the terms of the above identified grant or contract award from the United States Government. This document is confirmatory of:

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Signed this 26<sup>th</sup> day of June, 2015.

By Alicia I. Löffler, Ph.D.  
(Institutional Business Official)

  
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Title Associate Provost, Associate Vice President for Research, and Executive Director INVO

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